	Application No.	Applicant(s)		
	10/612,093	BAF FT AL.	BAE ET AL.	
Notice of Allowability	Examiner	Art Unit		
	Tan Ho	2821	<u>A</u>	
The MAILING DATE of this communication appe All claims being allowable, PROSECUTION ON THE MERITS IS herewith (or previously mailed), a Notice of Allowance (PTOL-85) NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RI of the Office or upon petition by the applicant. See 37 CFR 1.313	(OR REMAINS) CLOSED ir or other appropriate commu GHTS. This application is s	n this application. If not include unication will be mailed in due of	d course. <b>THIS</b>	
1. $\boxtimes$ This communication is responsive to <u>the pre-amendment fi</u>	iled on 7/03/2003.			
2. 🖾 The allowed claim(s) is/are <u>1-18</u> .				
3. $\boxtimes$ The drawings filed on <u>03 July 2003</u> are accepted by the Ex	aminer.			
<ul> <li>4.  Acknowledgment is made of a claim for foreign priority una a)  All b)  Some* c)  None of the:  1.  Certified copies of the priority documents have  2.  Certified copies of the priority documents have  3.  Copies of the certified copies of the priority documents nave  International Bureau (PCT Rule 17.2(a)).  * Certified copies not received:  Applicant has THREE MONTHS FROM THE "MAILING DATE" on oted below. Failure to timely comply will result in ABANDONM THIS THREE-MONTH PERIOD IS NOT EXTENDABLE.</li> <li>5.  A SUBSTITUTE OATH OR DECLARATION must be submit INFORMAL PATENT APPLICATION (PTO-152) which give  6.  CORRECTED DRAWINGS (as "replacement sheets") must  (a)  including changes required by the Notice of Draftspers  1)  hereto or 2)  to Paper No./Mail Date  (b)  including changes required by the attached Examiner's  Paper No./Mail Date  Identifying indicia such as the application number (see 37 CFR 1. each sheet. Replacement sheet(s) should be labeled as such in the  paper No./Mail OFR and/or INFORMATION about the depose  attached Examiner's comment regarding REQUIREMENT is  1.  DEPOSIT OF and/or INFORMATION about the depose  attached Examiner's comment regarding REQUIREMENT is  1.  DEPOSIT OF and/or INFORMATION about the depose  attached Examiner's comment regarding REQUIREMENT is  1.  DEPOSIT OF and/or INFORMATION about the depose  attached Examiner's comment regarding REQUIREMENT is  1.  DEPOSIT OF and/or INFORMATION about the depose  attached Examiner's comment regarding REQUIREMENT is  1.  DEPOSIT OF and/or INFORMATION about the depose  attached Examiner's comment regarding REQUIREMENT is  1.  DEPOSIT OF and/or INFORMATION about the depose  attached Examiner's comment regarding REQUIREMENT is  1.  DEPOSIT OF and/or INFORMATION about the depose  attached Examiner's comment regarding REQUIREMENT is  1.  DEPOSIT OF and/or INFORMATION about the depose  attached Examiner's comment regarding REQUIREMENT is  1.  DEPOSIT OF and/or INFORMATION about the depose  attached Examine</li></ul>	been received.  been received in Application cuments have been received of this communication to file ENT of this application.  itted. Note the attached EXA es reason(s) why the oath or t be submitted. on's Patent Drawing Review as Amendment / Comment or 84(c)) should be written on the header according to 37 CF sit of BIOLOGICAL MATE	on No  Id in this national stage applicated in this national stage applicated in this national stage applicated in the requirement of the declaration is deficient.  If (PTO-948) attached in the Office action of the drawings in the front (not the R 1.121(d).  ERIAL must be submitted. N	uirements  OTICE OF  back) of	
Attachment(s)  1. ☑ Notice of References Cited (PTO-892)  2. ☐ Notice of Draftperson's Patent Drawing Review (PTO-948)  3. ☐ Information Disclosure Statements (PTO-1449 or PTO/SB/0 Paper No./Mail Date  4. ☐ Examiner's Comment Regarding Requirement for Deposit of Biological Material	6. ☐ Interview St Paper No./ 8), 7. ☑ Examiner's	formal Patent Application (PTC ummary (PTO-413), Mail Date Amendment/Comment Statement of Reasons for Allow	ŕ	

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## **DETAILED ACTION**

## **EXAMINER'S AMENDMENT**

An examiner's amendment to the record appears below. Should the changes and/or additions be unacceptable to applicant, an amendment may be filed as provided by 37 CFR 1.312. To ensure consideration of such an amendment, it MUST be submitted no later than the payment of the issue fee.

✓ - In claim 1, line 5, change "the first metallic pattern" to -- the first metallic pattern <u>section</u>--.

This change was made to provide a proper antecedent basis in the claim.

## Allowable Subject Matter

The following is an examiner's statement of reasons for allowance:

Claim 1 recites a multi-band helical antenna comprising a dielectric body having a plurality of dielectric sheets stacked in a predetermined order, at least a first metallic pattern section and a second metallic pattern section provided in the dielectric body, the first metallic pattern section including a plurality of first partially opened metallic loop patterns and a plurality of first connection elements connecting the respective adjacent first partially opened metallic pattern to form a first spiral structure, and the second metallic pattern section including a plurality of second partially opened metallic loop patterns and a plurality of second connection elements connecting the respective adjacent second partially opened metallic pattern to form a second spiral structure, wherein the first and second metallic pattern sections have different entire lengths.

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Claim 2 recites a multi-band helical antenna comprising a dielectric body having a plurality of first dielectric sheets of a first thickness t1 and plurality of second dielectric sheets of a second thickness t2 that is different from t1, the dielectric sheets stacked in a predetermined order, at least a first metallic pattern section and a second metallic pattern section provided in the first dielectric sheets and the second dielectric sheets, the first metallic pattern section including a plurality of first partially opened metallic loop patterns spaced apart from each other by a first distance and a plurality of first connection elements connecting the respective adjacent first partially opened metallic patterns to form a first spiral structure, and the second metallic pattern section including a plurality of second partially opened metallic loop patterns spaced apart from each other by a second distance different from the first distance and a plurality of second connection elements connecting the respective adjacent second partially opened metallic patterns to form a second spiral structure.

Claim 3 recites a multi-band helical antenna comprising a dielectric body having a plurality of dielectric sheets stacked in a predetermined order, at least a first metallic pattern section and a second metallic pattern section provided in the dielectric body, the first metallic pattern section including a plurality of first partially opened metallic loop patterns having a first radius r1 and a plurality of first connection elements connecting the respective adjacent first partially opened metallic pattern to form a first spiral structure, and the second metallic pattern section including a plurality of second partially opened metallic loop patterns having a second radius r2 different from r1, and a plurality of second connection

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elements connecting the respective adjacent second partially opened metallic pattern to form a second spiral structure.

Claim 4 recites a multi-band helical antenna comprising a dielectric body having a plurality of dielectric sheets stacked in a predetermined order, at least a first metallic pattern section and a second metallic pattern section provided in the dielectric body, the first metallic pattern section including a plurality of first partially opened metallic loop patterns having a first entire length I1 and a plurality of first connection elements connecting the respective adjacent first partially opened metallic pattern to form a first spiral structure, and the second metallic pattern section including a plurality of second partially opened metallic loop patterns having a second entire length I2 different from I1, and a plurality of second connection elements connecting the respective adjacent second partially opened metallic pattern to form a second spiral structure.

None of the prior arts shows or suggests these helical antennas.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

## Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Tan Ho whose telephone number is (571) 272-1822. The examiner can normally be reached on M-F (8:00AM - 5:00PM).

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If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Don Wong can be reached on (571) 272-1834. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

TAN HO
PRIMARY EXAMINER